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Defect and strain engineered MoS₂/graphene catalyst for an enhanced hydrogen evolution reaction†

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Molybdenum disulfide (MoS₂) has been demonstrated as a promising non-precious metal electrocatalyst for the hydrogen evolution reaction (HER). However the efficiency of the HER falls short of expectations due to the large inert basal plane and poor electrical conductivity. In order to activate the MoS₂ basal plane and enhance the hydrogen evolution reaction (HER) activity, two strategies on the hybrid MoS2/graphene, including intrinsic defects and simultaneous strain engineering, have been systematically investigated based on density functional theory calculations. We firstly investigated the HER activity of a MoS₂/graphene hybrid material with seven types of point defect sites, V_{S} , V_{MO} , V_{MOS3} , V_{MOS6} , V_{MOS9} and $S2_{MO}$. Using the hydrogen adsorption free energy ($\Delta G_{\rm H}$) as the descriptor, results demonstrate that four of these seven defects (V₅, V₅₂, Mo₅₂, V_{Mo53}) act as a catalytic active site for the HER and exhibited superior electrocatalytic activity. More importantly, we found that ΔG_H can be further tuned to an ideal value (0 eV) with proper tensile strain, which effectively optimizes and boosts the HER activity, especially for the V_{S_t} , V_{SQ_t} , V_{MOS3} defects and Mo₅₂ antisite defects. Our results demonstrated that a proper combination of tensile strain and defect structure is an effective approach to achieve more catalytic active sites and further tune and boost the intrinsic activity of the active sites for HER performance. Furthermore, the emendatory d-band center of metal proves to be an excellent descriptor for determining H adsorption strength on defective MoS₂/ graphene hybrid material under different strain conditions. In addition, the low kinetic barrier of H₂ evolution indicated that the defective MoS₂/graphene system exhibited favorable kinetic activity in both the Volmer-Heyrovsky and the Volmer-Tafel mechanism. These results may pave a new way to design novel ultrahigh-performance MoS2-based HER catalysts.

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1. Introduction

The process of electrochemical water splitting to produce hydrogen energy *via* the hydrogen evolution reaction (HER) has been considered a renewable, green, and highly efficient technique. Pt and Pt-group metals are regarded as the best catalysts for the hydrogen evolution reaction (HER). However, these metals are a limited natural resource, which significantly elevates the cost of using these metals, thereby limiting their utilization in practice. These major issues make it essential to develop a naturally abundant and inexpensive material with

amount of attention as a promising non-precious metal catalyst for the hydrogen evolution reaction (HER). MoS₂ is low-cost, naturally abundant, has high chemical stability, and a comparable catalytic HER performance to Pt.2,3 However, MoS2 HER efficiency does not meet expectations because the catalytic activity of MoS₂ highly depends on its active edge sites, thereby rendering the large inert basal plane non-catalytic, as well as a poor electrical conductivity for the catalyst. 4 Many strategies are being explored to optimize the catalytic performances of MoS₂, including controlling the size of MoS₂ to expose more active edge sites using nanoparticles,5 nanowires,6 nanoflakes7 and nanotube,8 as well as coupling MoS2 with other conductive scaffolds, such as graphene, 9,10 carbon nanotube 11 and Au electrode,12 to improve electrical conductivity of MoS2 material and HER electrocatalytic activity. Chemical doping13 and defects formation14,15 are two additional methods used to improve the intrinsic active sites. Voiry et al. reported that the catalytic activity of the 2H-MoS2 basal plane was significantly enhanced

highly active HER performance as an alternative to Pt, but has remained a challenge thus far.

Recently, molybdenum disulfide (MoS₂) has attracted a large

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when the presence of sulfur vacancies were combined with an efficient charge injection between the conductive Au support and the catalyst.¹² Using argon plasma exposure, Tsai *et al.* have shown that S-vacancies on 2H-MoS₂ exhibited higher intrinsic activity in HER than at the edge sites.¹⁵

Recent research has additionally found that tuning strain is a powerful strategy for tailoring the catalytic activity to achieve the highest intrinsic HER activity. 16-18 The application of external strain on the $1T'-MX_2$ (M = Mo, W; X = S, Se, Te) significantly tunes and boosts the HER performance. 19 Li et al. have reported that introducing strain on the S vacancy-MoS₂ basal plane could enormously enhance its HER activity.20 Dimakis et al. have also examined the S, S₂ vacancies and C vacancies in the MoS2/graphene heterostructure could be engineered for producing efficient HER electrocatalysts based on density functional theory (DFT), but the reaction model by combining the molecular dynamics (MD) simulations are not considered.21,22 Recently, experimentation has systematically identified a variety of intrinsic defects prepared by chemical vapor deposition (CVD) grown monolayer MoS2.23,24 However, it is still unknown what potential roles would various combinations of the different intrinsic defects and engineered strains play on the HER performance of MoS2-based materials. It prompted us to investigate if strain engineering and different intrinsic defects simultaneously could increase both the number of active sites and intrinsic catalysis activity, thus exhibiting significantly enhanced HER performance for MoS2based hybrid materials.

In this study, we explored both the strain engineering and intrinsic defect strategies to optimize the hydrogen evolution reaction (HER) catalytic activity of the MoS₂ basal plane grown on graphene using the first-principles DFT calculation. Used 7 different types of point defects commonly observed in experiments includes a monosulfur vacancy (V_S) , a disulfur vacancy $(V_{\rm S2})$, an Mo vacancy $(V_{\rm Mo})$, a vacancy complex of Mo and three nearby sulfur (V_{MoS3}) , a vacancy complex of Mo and six nearby sulfur (V_{MoS6}) , antisite defects where an Mo atom substitutes for an S2 column (MoS2) and an S2 column substitutes for an Mo atom (S2_{Mo}). Our results show that MoS₂/graphene hybrid with intrinsic defects can activate the inert basal plane and greatly improve the HER activity. Furthermore, we found significant improvement of the HER intrinsic activity of the active site for the MoS₂/graphene hybrid material when we use a combination of a defect structure and a proper strain. Our results may pave an effective strategy to design ultrahighperformance MoS2-based HER catalysts.

2. Computational methods

2.1. Model systems

The optimized lattice parameters of monolayer MoS_2 and graphene were calculated to be 3.17 Å and 2.46 Å, respectively, which is well in agreement with the experimental and theoretical results. The supercell structure of the composite system is $(4 \times 4) MoS_2$ and (5×5) graphene, which includes about a 2.9% lattice mismatch. The lattice of graphene was initially set to match that of monolayer MoS_2 in the supercell, and then the

supercells fully relaxed for both the lattice constants and the atomic geometry. Eventually, the mismatch would finally disappear, leading to the commensurate systems. The relaxed lattice constants of the MoS₂/graphene system is approximately 12.44 Å. The lattice of parameter of MoS₂ layer in the supercell are slightly compressed by 1.9% (from 3.17 Å to 3.11 Å) when compared to the corresponding isolated sheet, while the graphene layer in the supercells are slightly expanded by 1.2% (from 2.46 Å to 2.49 Å). The lattice constants experienced a slight decrease for defective $MoS_2(V_S, V_{S2}, V_{MoS3}, V_{MoS6}, Mo_{S2})$ graphene systems, while lattice constants for V_{Mo}-MoS₂/graphene and S2_{Mo}-MoS₂/graphene systems remained mostly unchanged, both with respect to a perfect MoS₂/graphene system. The monolayer MoS2 have the direct band gap of 1.73 eV at the k point. While for MoS_2 /graphene, a tiny band gap of about 2 meV is opened in the Dirac cone of graphene. It is indicated that the combination of the chemically inert graphene with MoS₂ as van der Waals heterostructure provides better electron conduction and ion transportation, result in improvement of the electrocatalytic performance (Fig. S1†).

The reaction mechanism was investigated by constructing a solid/liquid interfacial model, which was modeled with the substrate covered by two water layers. The water-solid interface was obtained by combining the molecular dynamics (MD) simulations and structural optimization. Molecular dynamics (MD) simulations were initially performed using the LAMMPS package to equilibrate the structure of water molecules at the interface of monolayer MoS2.28 The rectangular supercell of monolayer MoS2 had a rectangular dimension of approximately $21.545 \times 24.878 \,\text{Å}^2$ in x and y direction, respectively, and a water film initially placed on the top of the surface contained a total number of 538 H₂O molecules. Periodic boundary conditions were applied in all three directions and a vacuum 5.0 nm thick was added above the water film to prevent interactions between the periodic images. We employed the flexible extended simple point charge (SPC/E) model²⁹ for the water solvent and maintained a fixed surface structure during the simulation. The employed force field for MoS2 was developed by Heiranian et al.,30 which has been demonstrated to reproduce excellent water-MoS₂ interface properties. The cutoff distance for the non-bonded interactions was set to be 10.0 Å, and the longrange electrostatic interactions were calculated using the particle-particle particle-mesh method (PPPM).31 The canonical ensemble (NVT) was applied during the simulation, temperature was held at 300.0 K via the Nose-Hoover method, and the coupling coefficient was 0.1 ps. The entirety of the simulation was completed in 20.0 ns, where the first 10.0 ns was for equilibrium and the remaining 10.0 ns were used for data collection. Afterwards, the interface water molecules were first extracted from the equilibrium structure and then a hexagonal cell was cleaved from the obtained structure (see Fig. S2†), which was used for the subsequent DFT calculations. The dimension of the monolayer MoS₂ is 12.44 \times 12.44 Å^2 and there are totally 32 water molecules on the surface. Proton concentration can be changed when hydrogen atoms are added into the systems. The H atom forms proton either through being adsorbed on the surface or solvated in the water layer. The water-solid interfaces **RSC Advances**

with two layers of proton-laden water molecules were used to simulate the electrical double layer in an acid solution.

2.2. Computational methods

Spin-polarized density functional theory (DFT) calculations were carried out using the Vienna ab initio simulation package (VASP).32-34 The projector augmented wave method was certified to describe the interaction between electrons and ions,35 and the generalized gradient approximation (GGA) of the Perdew-Burke-Ernzerhof (PBE) functional exchange-correlation functional was employed.³⁶ The pseudopotentials with 4p₆5s₁4d₅, 3s₂3p₄, 2s₂2p₂ and 1s₁ are used for Mo, S, C and H atoms here under PAW, respectively. The kinetic cutoff energy for the planewave expansion was set to 500 eV. The spacing between the adjacent slabs was set to about 15 Å, and a (5 \times 5 \times 1) Monkhorst-Pack mesh was used for the k-point sampling of the Brillouin zone. DFT-D3 calculations were used to describe the weak interactions.³⁷ During structural optimization, all the internal coordinates were fully relaxed in all directions. The HER activity of the catalyst was evaluated by calculating the free energy of the adsorption atomic hydrogen ($\Delta G_{\rm H}$), which can be obtained by $\Delta G_{\rm H} = \Delta E_{\rm H} + \Delta E_{\rm ZPE} - T\Delta S_{\rm H}$. The $\Delta E_{\rm H}$ presents the adsorption energy of the nth H atom, which is defined as: $\Delta E_{\rm H} =$ $E_{\text{MoS2/graphene+}nH} - E_{\text{MoS2/graphene+}(n-1)H} - 1/2 E_{\text{H2}}$, where $E_{\text{MoS2-}graphene+}$ graphene+nH and $E_{MoS2-graphene+(n-1)H}$ represents the total energy of the MoS_2 /graphene system with n and n-1 adsorbed H atoms on the surface, respectively, while $E_{\rm H2}$ represents the total energy of H_2 in gas phase. The $\Delta E_{\rm ZPE}$ is the zero-point energy difference between the adsorbed state of the different defective MoS_2 /graphene system and the gas-phase state, the ΔS_H is obtained by $\Delta S_{\rm H} \cong -1/2 S_{\rm H2}^0$, and the $S_{\rm H2}^0$ is the entropy of H₂ in gas phase at standard condition ($S_{\rm H2}^0 \sim 130~{\rm J~mol~K}^{-1}$).³⁸ The diffusion energy barrier and the minimum energy pathways for H₂ evolution were determined using the climbing-image nudged elastic band (CI-NEB) method,39 and each transition state was further confirmed by vibrational frequency analysis.

3. Results and discussion

3.1. Gibbs free energy ($\Delta G_{\rm H}$) of atomic hydrogen on MoS₂-graphene system with the different intrinsic defects and strain engineering

We first studied the HER activity of the $MoS_2/graphene$ hybrid material with different intrinsic defects(V_S , V_{S2} , V_{MO} , V_{MOS3} , V_{MOS6} , Mo_{S2} and $S2_{MO}$, respectively). We started with various possible adsorption sites on MoS_2 -graphene system for a single H atom with each intrinsic defects were considered. The most stable adsorption configurations are shown in Fig. 1. Results show that after different intrinsic defects are introduced, the binding of the H atom with the defective $MoS_2/graphene$ hybrid materials stabilizes. The H atom showed location preference at the S vacancy for the $MoS_2/graphene$ system with the V_S and V_{S2} defects, and with the MoS_2 defects, the H atom showed preference to bond with one Mo atom. The H atom connected the bridge site between two Mo atoms with the V_{MoS3} and V_{MoS6} defects, but with V_{MO} and $S2_{MO}$ defects, the H atom interacted

with top site of S atom instead with Mo site. The Gibbs free energy for hydrogen adsorption on a catalyst surface ($\Delta G_{\rm H}$) has been demonstrated to be a good descriptor for HER activity, as shown in Nørskov's analyses. 40 An ideal $\Delta G_{\rm H}$ on catalyst should be close to 0 eV where hydrogen is bonded neither too strongly nor too weakly. Therefore, we calculated the single H atom adsorption free energy ($\Delta G_{\rm H}$) for MoS₂/graphene system with different intrinsic defects (V_S , V_{S2} , V_{Mo} , V_{MoS3} , V_{MoS6} , Mo_{S2} and S2_{Mo}), as shown in Fig. 2A. The result show that after different intrinsic defects (V_S , V_{S2} , V_{Mo} , V_{MoS3} , V_{MoS6} , Mo_{S2} and $S2_{Mo}$) are introduced, the calculated $\Delta G_{\rm H}$ for each defect is much lower than the defect-free basal plane (1.9 eV),41 indicating that intrinsic defects can bring additional active site and trigger HER activity of the inert basal plane. This finding agrees with previous experimental studies, where the active sites were the vacancies created on the 2H-MoS₂. ¹⁵ For the case of V_{MoS6} , the calculated $\Delta G_{\rm H}$ is very negative, demonstrating that the interaction is too strong to ensure a facile bond breaking and the release of gaseous H₂. It is worth noting that the ΔG_H for V_S , V_{S2} , $V_{\text{MoS}3}$ and Mo_{S2} defects is only 0.04 eV, 0.09 eV, -0.14 eV and -0.07 eV, respectively, which was close to an ideal value (0 eV). It is indicated that these 4 kinds of defects have highly catalytic activity for the Volmer reaction. These values are approximate to or are better than the Pt value (-0.09 eV) or Mo edge (0.08 eV), indicating that defective MoS2/graphene system had higher intrinsic HER activity with the $V_{\rm S}$, $V_{\rm S2}$, $V_{\rm MoS3}$ and Mo_{S2} defects. We have examined the sub-layer effect on the defective MoS₂/ graphene systems at different strain engineering. We found that, after H adsorption on the defective MoS₂/graphene system, the Mo-Mo distance and the length of Mo-S bond between sublayer Mo atom and top layer S atom around the defect are changed a little. It is indicated that the energy cost induced by structural changes with H adsorption are very small. The result is also agreement with the further investigation of the calculated structure reconstruction energy ($\Delta E_{\rm R}$) for all the different defective MoS₂/graphene systems, which is the energy cost induced by structural changes with H adsorption. We calculated the energy of structural reconstruction, $\Delta E_{\rm R}$, by subtracting the energy of the adsorption structure with H removed from the energy of the clean structure without H adsorption. Except for the $V_{\text{MoS}3}$ defect, it is can be seen that, values of ΔE_{R} are very small for the defective MoS₂/graphene systems, suggesting that the defective MoS₂/graphene systems can retain good structural stability during the hydrogen adsorption and release.

Next, we explored whether intrinsic defects and strain engineering simultaneously could bring better HER activity for MoS₂/graphene hybrid material. We further explored the effects of biaxial strain on these defective MoS₂/graphene with a series of intrinsic defects($V_{\rm S}$, $V_{\rm S2}$, $V_{\rm Mo}$, $V_{\rm MoS3}$, $V_{\rm MoS6}$, MoS₂ and S2_{Mo}). Fig. 2B and C display a variation in $\Delta G_{\rm H}$ under biaxial strains ranging from -5 to +5% for seven kinds of defective MoS₂-graphene system by varying the lattice parameters (Fig. 1). As evident in Fig. 2, it is interesting to note that the defects have different responses to strain. As for the MoS₂/graphene system with $V_{\rm S}$, $V_{\rm S2}$, $V_{\rm MoS3}$ and MoS₂ defects (Fig. 2B), under biaxial strains ranging from -5 to +5%, they achieved the ideal value of $\Delta G_{\rm H}$ of approximately 0 eV at 1%, 1%, 4% and 1% tensile strain,

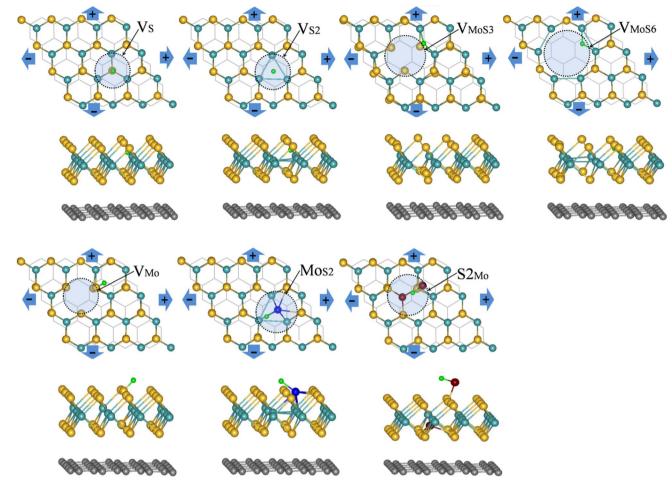


Fig. 1 The top and side views of the most stable position for single H atom adsorbing at MoS₂/graphene system with different intrinsic defects $(V_S, V_{S2}, V_{MoS3}, V_{MoS6}, V_{Mo}, Mo_{S2})$ and $S2_{Mo}$, respectively) at strain engineering. The yellow, cyan and green balls present S, Mo and H atoms, respectively, the brown and dark blue balls stand for atom replaced by S and Mo atoms respectively, the bottom black line or balls refer to the graphene.

respectively. It is indicated the $V_{\rm S}, V_{\rm S2}, V_{\rm MoS3}$ and Mo_{S2} defects particularly had optimal responses to different tensile strains with optimal $\Delta G_{\rm H}$ values (\sim 0 eV) and effectively tune and boost the intrinsic activity of defective MoS₂/graphene hybrid materials. In contrast, for the $MoS_2/graphene$ hybrid with the V_{Mo} , V_{MoS6} and $S2_{\text{Mo}}$ defects (Fig. 2C), when applying biaxial strains

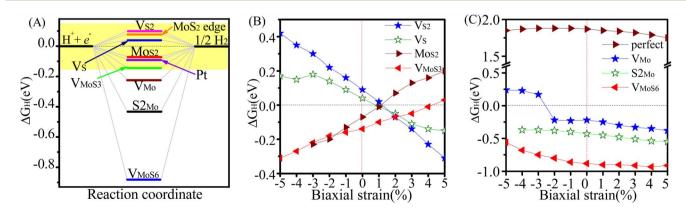


Fig. 2 (A) ΔG_H for HER on MoS₂/graphene catalysts with different intrinsic defects (V_S , V_{S2} , V_{Mo} , V_{MoS3} , V_{MoS6} , Mo_{S2} , $S2_{Mo}$), MoS₂ edge and Pt, respectively. The result of Pt catalyst and MoS₂ edge is taken from ref. 3. (B) ΔG_H for HER on MoS₂/graphene catalysts with different intrinsic defects (V_S, V_{S2}, V_{MoS3}, Mo_{S2}) versus %x-biaxial strain ranging from -5 to +5%. (C) ΔG_H for HER on perfect MoS₂/graphene and MoS₂/graphene systems with different intrinsic defects (V_{Mo} , S2_{Mo}, V_{MoS6}) versus %x-biaxial strain ranging from -5 to +5%.

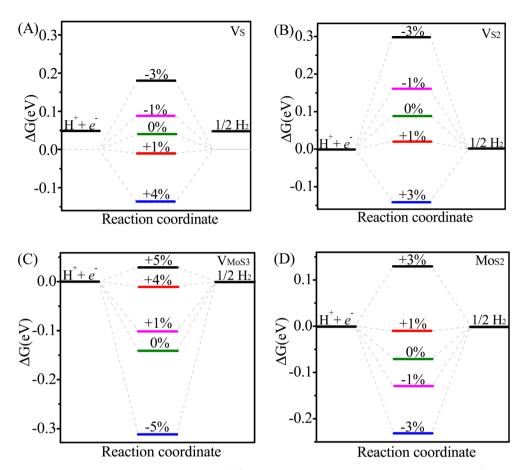


Fig. 3 Effect of strain on the HER performance of different $MoS_2/graphene$ catalysts with different intrinsic defects (V_S , V_{MOS3} , Mo_{S2}): free energy(ΔG_H) diagram for the HER on different catalysts at different strain: (A) $V_S-MoS_2/graphene$, (B) $V_{S2}-MoS_2/graphene$, (C) $V_{MOS3}-MoS_2/graphene$, (D) $Mo_{S2}-MoS_2/graphene$.

for either positive strain (tensile strain) or negative strain (compressive strain), although there is moderate drop in $\Delta G_{\rm H}$, the $\Delta G_{\rm H}$ are all larger than |0.22 eV|, |0.5 eV| and |0.3 eV|, respectively, proved insufficient to optimize HER activity of the MoS_2 /graphene hybrid with the V_{Mo} , V_{MoS6} and $S2_{Mo}$ defects, responses to biaxial strains. Fig. 3 further shows the effect of strain on hydrogen binding free energy with V_S -Mo_{S2}/graphene, V_{S2} -MoS₂/graphene, V_{MoS3} -MoS₂/graphene and Mo_{S2}-MoS₂/ graphene. It can be seen clearly, there was a negative strain (compressive strain) for the V_S defect with a 3% increase of the $\Delta G_{\rm H}$ to 0.18 eV. It is noteworthy that, a small positive strain (tensile strain) of 1% dropped $\Delta G_{\rm H}$ to -0.01 eV, which is very close to the ideal value of $\Delta G_{\rm H}$ (0 eV). It is indicated hydrogen adsorption was significantly stronger and subsequently HER activity improved. Interestingly, in the absence of strain, the $\Delta G_{\rm H}$ was calculated at 0.09 eV in $V_{\rm S2}$ -MoS₂/graphene system. Biaxial tensile strain tends to lower the $\Delta G_{\rm H}$. It appeared to catch up with that case of V_S defect and eventually become significantly more active at modest tensile strain (1%) with the ideal value of $\Delta G_{\rm H}$ of approximately 0 eV, which is the best value for potential HER activity (Fig. 2B). The $\Delta G_{\rm H}$ and H adsorption strength of MoS_2 /graphene hybrid with V_{MoS_3} and Mo_{S_2} defect also showed sensitivity to biaxial strain. However, biaxial tensile strain tended to weaken hydrogen adsorption for V_{MoS3} and

 ${
m Mo_{S2}}$, which differed from the $V_{
m S}$ and $V_{
m S2}$ defect, where which biaxial tensile strain strengthened the hydrogen adsorption. The $V_{
m MoS3}$ and ${
m Mo_{S2}}$ defect achieved a more favorable $\Delta G_{
m H}$ (close to 0) at 4% and 1% tensile strain, respectively, which resulted in higher HER activity.

Therefore, biaxial tensile strains proves to be a good regulator for bringing the $\Delta G_{\rm H}$ to 0 eV and effectively tune and boost the intrinsic activity of MoS₂/graphene hybrid materials with $V_{\rm S}$, $V_{\rm S2}$, $V_{\rm MoS3}$ defects and MoS₂ antisite defects. The $V_{\rm S}$, $V_{\rm S2}$, $V_{\rm MoS3}$ defects and MoS₂ antisite defects particular had optimal responses in the tensile-strained MoS₂/graphene hybrid with optimal $\Delta G_{\rm H}$ values approximately 0 eV. It is indicated that combinations of defect structure and proper strain can significantly improve the HER activity of the MoS₂/graphene hybrid material. These combinations were comparatively better than the defect-free MoS₂/graphene under biaxial strains condition, which had $\Delta G_{\rm H}$ all larger than 1.60 eV when applying biaxial strains ranging from -5 to +5%. These results indicate that the strain alone is insufficient to activate the basal plane (Fig. 2C).

3.2. Electronic structures of MoS₂/graphene system with the different intrinsic defects and baixial strain

To better understand the origin of the different intrinsic defects and strain engineering on the HER mechanism for defective Paper

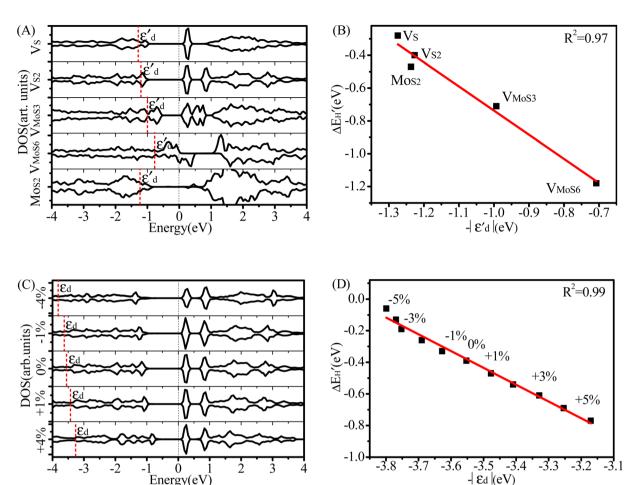


Fig. 4 (A) Spin-polarized densities of states (DOS) projected on 4d states of surface active Mo atoms for MoS₂/graphene system with different intrinsic defects: V_S , V_{S2} , V_{MoS3} , V_{MoS6} and MoS₂, respectively. The vertical black dashed line indicates the position of the Fermi level, taken as zero energy. (B) Relationship between $\Delta E_H'$ and $-\left|\varepsilon_d'\right|$ for various defects: V_S , V_{S2} , V_{MoS3} , V_{MoS6} and MoS₂ cases, respectively. (C) Spin-polarized densities of states (DOS) projected on 4d states of surface active Mo atoms for V_{S2} -MoS₂/graphene system at different biaxial strains: -4%, -1%, 0%, +1%, respectively. (D) Relationship between $\Delta E_H'$ and $-\left|\varepsilon_d\right|$ for V_{S2} -MoS₂/graphene system under -5 to +5% biaxial strain condition.

MoS₂/graphene hybrid materials, we analyzed the electronic structures of these composite materials with intrinsic defects and strain engineering. Firstly, we analyzed the electronic properties of these defective MoS₂/graphene systems. The total density of states (TDOS) for MoS_2 /graphene system with V_S , V_{S2} , V_{MoS3} , V_{MoS6} and Mo_{S2} are investigated, as displayed in Fig. S3.† We observed there are noticeable states appearing near the Fermi level, which is significantly different from the case of defect-free MoS₂/graphene system. Since hydrogen atoms directly interact with the Mo site for MoS2/graphene system with $V_{\rm S}, V_{\rm S2}, V_{\rm MoS3}, V_{\rm MoS6}$ and Mo_{S2} defects, we further focused on the spin-polarized densities of states (DOS) projected on 4d states of surface active Mo atoms that participate in the interaction with the H atom in the MoS_2 /graphene system with V_S , V_{S2} , V_{MoS3} , V_{MoS6} and Mo_{S2}, respectively (Fig. 4A). We can further conclude that the states appearing near the Fermi level is dominated by 4d state of the Mo site. When the H 1s orbital interacts with these new d states, it produces a bonding orbital and an antibonding orbital, where the degree of orbitals overlapping near the Fermi level determines the strength of the Mo-H chemical

bonds. To understand this further, we used the d-band center theory of the metals to find an appropriate descriptor by using the d states of Mo atoms to determine the interaction strength. We then plotted the chemical bonding energy between H and the substrate, $\Delta E_{\rm H}'$, against the value of the d band center, $\varepsilon_{\rm d}$. The H adsorption energy ($\Delta E_{\rm H}$) consists of two parts: the chemical bonding energy of H ($\Delta E_{\rm H}'$), and structural reconstruction energy ($\Delta E_{\rm R}$), so the chemical bonding energy is defined as $\Delta E_{\rm H}' = \Delta E_{\rm H} - \Delta E_{\rm R}$. The value of $\varepsilon_{\rm d}$ is calculated by following equation:

$$\varepsilon_{\rm d} = \frac{\int_{-\infty}^{E_{\rm F}} E \rho(E) dE}{\int_{-\infty}^{E_{\rm F}} \rho(E) dE} \tag{1}$$

As shown in Fig. S4,† $\Delta E'_{\rm H}$ does not exhibit a good linear correlation with $\varepsilon_{\rm d}$ for defective MoS₂/graphene systems with $V_{\rm S}$, $V_{\rm S2}$, $V_{\rm MoS3}$, $V_{\rm MoS6}$ and MoS₂, respectively. However, when we changed the integral energy region to range of -1.5 eV– $E_{\rm F}$, named $\varepsilon'_{\rm d}$, $\Delta E'_{\rm H}$ displayed a nearly linear relationship with $\varepsilon'_{\rm d}$ for the same five types of defective MoS₂/graphene system

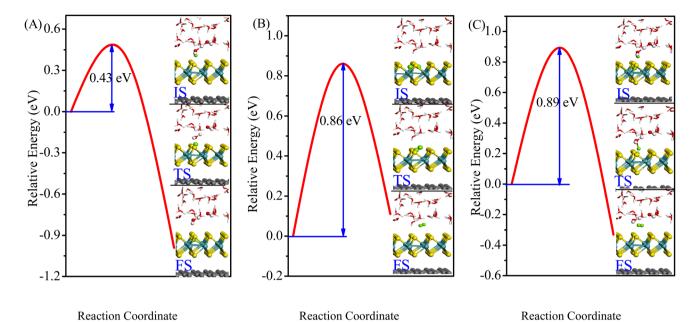


Fig. 5 Minimum-energy pathways of Volmer, Tafel and Heyrovsky reactions on V_{S2} -MoS₂/graphene system. The inserts are the corresponding initial state (IS), transition state (TS), and final state (FS).

(Fig. 4B), which indicates that the interaction strength between the H atom and the substrate determined by the Mo-4d state under and near the $E_{\rm F}$. As the $\varepsilon'_{\rm d}$ more approaches $E_{\rm F}$, the Mo–H bonding more strengthens. While the other two defective MoS $_2/$ graphene systems ($V_{\rm Mo}$ and S2 $_{\rm Mo}$ defects), the H atom tend to interact directly with S atoms, and would have significant relationships between the S-3p and H-1s states. Therefore, we considered the projected DOS of S-3p state and corresponding integral energy, $\varepsilon_{\rm p}$ (Eqn (1)), which showed a similar H interact with S site. In the same manner, as $\varepsilon_{\rm p}$ more approaches $E_{\rm F}$, the S–H bonding more strengthens (Fig. S5†).

Using the $V_{\rm S2}$ -MoS₂/graphene system as an example, we next examined the partial DOSs of V_{S2}-MoS₂/graphene system at different biaxial strains to understand the mechanism of the variations of $\Delta G_{\rm H}$ tuned by strain engineering, as shown in Fig. 4C. Results show that the introduction of the strain engineering causes a visible shift of the 4d states of the Mo atom directly interacting with adsorbed H atom. The gradually shifts of the Mo-4d state are in excellent agreement with the variation of the biaxial strains. With positive strains (tensile strains), these states gradually shift upwards and move close to the Fermi level, resulting in a gradual strengthening of H binding. These states shift downward and away from the E_F with negative strains (compressive strains), which can clearly explain the weakening of the H interaction with Mo atom in V_{S2} MoS₂/graphene. It is suggested that the proper tensile strain tunes the 4d state of the Mo atom, which results in a moderate $\Delta G_{\rm H}$ (Fig. 2B) and higher HER activity. This shows that the strain can be effectively engineered to optimize the hydrogen adsorption strength and achieve ultra-high HER activity. Next, we graphed the relationship between chemical bonding energy, $\Delta E_{\rm bond}$, and the values of d band center, $\varepsilon_{\rm d}$ (Eqn(1)), for $V_{\rm S2}$ -MoS₂/graphene system under the biaxial strain condition with a range of -5 to

5% (Fig. 4D) for the purpose of analyzing Mo–H chemical bonds strength variation under the strain engineering. $\Delta E_{\rm bond}$ exhibits a nearly linear trend with $\varepsilon_{\rm d}$ of the Mo atom by a coefficient of determination of $R^2=0.99$, suggesting that the strength of H binding is actually largely determined by the Mo-4d states. That the emendatory d-band center of metal can provide as an excellent descriptor for determining H adsorption is of great significance, which may pave the way to design ultrahighperformance MoS₂-based HER catalysts.

3.3. Reaction mechanism analysis

Once we have examined the Gibbs free energy for defective MoS₂/Graphene hybrid materials, we next investigated the kinetic energy barriers for H2 revolution using defective VS2-MoS₂/Graphene hybrid materials as a representative. The minimum-energy pathways and corresponding initial state (IS), transition state (TS) and final state (FS) are shown in Fig. 5. For HER in acid media, two types of possible pathways have been explored for H2 evolution: Volmer-Heyrovsky or the Volmer-Tafel mechanism. The Volmer reaction is the first step of the HER, in which a hydronium is transferred from the acid solution to a S2 vacancy ($H^+ + e^- \rightarrow H_{ads}$) as shown in Fig. 5A. The calculated barrier (E_a) is 0.43 eV, which is consistent with previous results.42 The Heyrovsky or Tafel mechanisms were candidates for the second step of the HER process, therefore both barriers of Tafel and Heyrovsky reaction on this active site were explored, as shown in Fig. 5B and C, respectively. In the Tafel step, two adsorbed H atoms reacted to form H₂ with a barrier of 0.86 eV, which indicated that electrons could easily form H2 from the adsorbed state. The values of the Tafel reaction for V_{S2}-MoS₂/Graphene hybrid materials were much lower than the Mo-edge of a single MoS_2 sheet (\sim 1.24 eV) reported in

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previous work by Huang. 43 We then predicted activation barrier of 0.89 eV in the Heyrovsky step, where the proton in the water layer reacts with the adsorbed H to form H2, which is in agreement with the barrier of 0.86 eV estimated from experimental turnover frequency (TOF) for per Mo atom on the Mo edge for hydrogen evolution of MoS2.4 The ultralow kinetic barrier both for Volmer-Tafel reaction and Volmer-Heyrovsky reactions suggested that the defective V_{S2}-MoS₂/graphene system exhibits excellent HER kinetic activity.

4. Conclusions

In summary, we have verified two possible approaches to effectively activate the MoS₂ basal plane grown on graphene and greatly improve hydrogen evolution reaction (HER) activity on the basis of first-principles DFT calculation, intrinsic defects and strain engineering simultaneously. We systematically investigated HER activity of MoS₂/graphene hybrid material with seven experimentally produced point defects sites, $V_{\rm S}$, $V_{\rm S2}$, V_{Mo} , V_{MoS3} , V_{MoS6} , Mo_{S2} and S2_{Mo}. Our results suggest that four types of those defects $(V_S, V_{S2}, Mo_{S2}, V_{MoS3}, respectively)$ can act as a catalytic active site for HER and exhibit superior electrocatalytic activity. Furthermore, we demonstrated that $\Delta G_{\rm H}$ can be further tuned to an ideal value (\sim 0 eV) using intrinsic defects and a proper tensile strain simultaneously, which effectively optimizes and boosts the intrinsic HER activity of the active sites, especially for V_S , V_{S2} , V_{MoS3} defects and Mo_{S2} antisite defects under the biaxial tensile strain of 1%, 1%, 4% and 1%, respectively. Interestingly, we found that the emendatory dband center of metal can serve as an excellent descriptor to determine chemical bonding energy between H and defective MoS₂/graphene hybrid material under different strain condition. Furthermore, the calculated low kinetic barrier of H₂ evolution on the V_{S2} -MoS₂/graphene system indicated that the defective MoS₂/graphene system exhibits excellent HER activity in both the Volmer-Heyrovsky and the Volmer-Tafel mechanisms. Therefore, the methodology of combining intrinsic defect and strain engineering has been shown to be an effective approach for producing a more catalytic active site and improving the HER activity of the MoS₂/graphene hybrid and other two-dimensional materials, which may provide a new way to design ultrahigh-performance MoS_2 -based HER catalysts.

Conflicts of interest

There are no conflicts to declare.

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